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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : RIBAK, E.  
Application No. : 09/613,759  
Filed : July 11, 2000  
Title : VOLTAGE AND LIGHT INDUCED STRAINS IN POROUS  
CRYSTALLINE MATERIALS AND USES THEREOF  
Group/Art Unit : 2834  
Examiner : Julio C. Gonzalez  
Attorney Docket No. : 00/20096

TO 28.0 LINE 00M

Honorable Commissioner of Patents and Trademarks  
Washington, D.C. 20231

## AMENDMENT

Sir:

This is in response to the United States Patent and Trademark Office Action mailed July 18, 2001, which response is being made on or before December 18, 2001, and for which two months of extension fees are due. Please amend the above identified application as follows:

In the Specification:

Please replace the paragraph beginning at page 36, line 1, with the following rewritten paragraph:

41  
-- Figure 7 shows an adaptive reflector in accordance with the teachings of the present invention, which is referred to hereinbelow as reflector 80. Reflector 80 includes a first layer 82 of porous crystalline material which is attached to, or integrally formed with, a second layer 84 having a reflective surface 86. Surface 86 may be formed as a reflective coat over